Patent

Attorney Docket No. 1000023-000180

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re F	Patent Application of	ATTN: ISSUE FEE
Takey	a Abe et al.	Allowed: December 2, 2009
Applic	ation No.: 09/936,514	Group Art Unit: 1652
Filed:	September 14, 2001	Examiner: Christian L. Fronda
For:	METHOD OF PURIFYING AMIDE COMPOUND	Confirmation No.: 4410

SECOND REQUEST FOR CORRECTED OFFICIAL FILING RECEIPT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

Further to the First Request for Corrected Official Fling Receipt filed April 29, 2002, enclosed is a copy of the Official Filing Receipt marked to show a correction that is needed. The correction is as follows:

Domestic Priority data as claimed by applicant THIS APPLICATION IS A 371 OF PCT/JP01/00313 00131 01/12/2001

This correction is in accordance with the Declaration and Power of Attorney (copy attached) filed September 14, 2001 in the above-identified patent application. Also enclosed are copies of the PCT Notification of Receipt of Record Copy dated February 15, 2001 and the front page of WO 01/53253 A1showing the correct PCT application number. These documents were previously made of record in the above-identified patent application. Issuance of a corrected Official Filing Receipt is respectfully requested.

Respectfully submitted,
BUCHANAN INGERSOLL & ROONEY PC

Date: December 10, 2009

Robert G. Mukai

Registration No. 28531

Customer No. 21839 703 836 6620



United States Patent and Trademark Office

COMMISSIONER FOR PATENTS
UNITED STATES PATENT AND TRADEMARK OFFICE
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CONFIRMATION NO. 4410

REPLACEMENT FILING RECEIPT

OC0000000007617685

Robert G Mukai Burns Doane Swecker & Mathis PO Box 1404 Alexandria, VA 22313-1404

Date Mailed: 03/11/2002

Receipt is acknowledged of this nonprovisional Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please write to the Office of Initial Patent Examination's Customer Service Center. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

Applicant(s)

Takeya Abe, Chiba, JAPAN; Kiyoshi Itou, Chiba, JAPAN; Kenju Sasaki, Chiba, JAPAN; Selichi Watanabe, Chiba, JAPAN; Tamotsu Asano, Chiba, JAPAN;

Domestic Priority data as claimed by applicant

THIS APPLICATION IS A 371 OF PCT/JP01/00343 01/12/2001

15100

Foreign Applications

JAPAN 2000-7993 01/17/2000

Projected Publication Date: To Be Determined - pending completion of Security Review

Non-Publication Request: No

Early Publication Request: No

Title

Method of purifying amide compound

Preliminary Class

LICENSE FOR FOREIGN FILING UNDER Title 35, United States Code, Section 184 Title 37, Code of Federal Regulations, 5.11 & 5.15

GRANTED

The applicant has been granted a license under 35 U.S.C. 184, if the phrase "IF REQUIRED, FOREIGN FILING LICENSE GRANTED" followed by a date appears on this form. Such licenses are issued in all applications where the conditions for issuance of a license have been met, regardless of whether or not a license may be required as set forth in 37 CFR 5.15. The scope and limitations of this license are set forth in 37 CFR 5.15(a) unless an earlier license has been issued under 37 CFR 5.15(b). The license is subject to revocation upon written notification. The date indicated is the effective date of the license, unless an earlier license of similar scope has been granted under 37 CFR 5.13 or 5.14.

This license is to be retained by the licensee and may be used at any time on or after the effective date thereof unless it is revoked. This license is automatically transferred to any related applications(s) filed under 37 CFR 1.53(d). This license is not retroactive.

The grant of a license does not in any way lessen the responsibility of a licensee for the security of the subject matter as imposed by any Government contract or the provisions of existing laws relating to espionage and the national security or the export of technical data. Licensees should apprise themselves of current regulations especially with respect to certain countries, of other agencies, particularly the Office of Defense Trade Controls, Department of State (with respect to Arms, Munitions and Implements of War (22 CFR 121-128)); the Office of Export Administration, Department of Commerce (15 CFR 370.10 (j)); the Office of Foreign Assets Control, Department of Treasury (31 CFR Parts 500+) and the Department of Energy.

NOT GRANTED

No license under 35 U.S.C. 184 has been granted at this time, if the phrase "IF REQUIRED, FOREIGN FILING LICENSE GRANTED" DOES NOT appear on this form. Applicant may still petition for a license under 37 CFR 5.12, if a license is desired before the expiration of 6 months from the filing date of the application. If 6 months has lapsed from the filing date of this application and the licensee has not received any indication of a secrecy order under 35 U.S.C. 181, the licensee may foreign file the application pursuant to 37 CFR 5.15(b).

COMBINED DECLARATION AND POWER OF ATTORNEY (Includes Reference to Provisional and PCT International Applications) Attorney Docket Number						
My residence, I believe I am plural names a <u>Process for P</u>	post office addre the original, first tre listed below) urifying Amide (of the subject matter which is c	name is listed below) or an or laimed and for which a paten	iginal, first and joint inventor (if t is sought on the invention entitled:		
	is attached her	eto.				
	was filed as United States application Number					
	and was amend					
\boxtimes	on(if applicable) was filed as PCT international application Number PCT/JP01/00131 on 12.01,2001					
		led under PCT Article 19	(if applicable).			
I acknowledge Code of federal III I hereby claim inventor's certi America listed international a	the duty to discle Regulations, §1. foreign priority I ficate or of any I below and have pplication(s) des	ferred to above. 56. 56. 56. Conefits under Title 35, United CT internations, applications, also identified below any forcing also identified below any forcing	known to me to be material States Code §119 (a) (e) of an designating at least one count application(s) for patent or ther than the United states of	to patentability as defined in Title 37, by foreign application(s) for patent or intry other than the United states of inventor's certificate or any PCT fAmerica filed by me on the same ned:		
		PLICATION(S) AND ANY	PRIORITY CLAIMS UN	DER 35 U.S.C. §119:		
COUI(if#CT, indi		APPLICATION NUMBER	DATE OF FILING (Day. Month. Year)	PRIORITY CLAIMED UNDER 35 U.S.C. §119		
JAF	AN	2000-7993	17.01.2000	× Yes No		
PCT PCT/JP01/00131		12.01.2001	No			
· ·						
I hereby claim	the benefit unde	r title 35, United States Code §	119(e) of any United States p	provisional application(s) listed below.		
(Арр	lication Number		(Filing Date)			
(Арр	lication Number		(Filing Date)			

COMBINED DECLARATION FOR PATENT APPLICATION AND POWER OF ATTORNEY (CONTINUED) (Includes Reference to Provisional and PCT International applications)

Attorney Docket No.

I hereby claim the benefit under title 35, United States code, § 120 of any United States applications(s) or PCT international application(s) designating the United States of America that is /are listed below and, insofar as the subject matter of each of the claims of this application is not disclosed in that/ those prior application(s) in the manner provided by the first paragraph of Title 35, United States Code, § 112, I acknowledge the duty to disclose to the Office all information known to me to be material to the patentabili by as defined in Title 37, code of Federal Regulations § 1.56, which became available between the filing date of the prior application(s) and the national or PCT international filing date of this application:

PRIOR U.S. APPLICATIONS OR PCT INTERNATIONAL APPLICATIONS DESIGNATING THE U.S. FOR BENEFIT UNDER 35 U.S.C. 120:

U.S. APPLICATIONS			STATUS (check one)			
U.S. APPLICATION	NUMBER	U.S. FILING DATE	PATENTED	PENDING	ABANDONED	
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PCT AP	PLICATIONS DESIGN.	ATING THE U.S.				
PCT APPLICATION NO.	PCT FILING DATE	U.S. APPLICATION NUMBERS ASSIGNED (if any)				
PCT/JP01/00131	12.01.2001					
	<u> </u>					

I hereby appoint the following attorneys and agent(s) to prosecute said application and to transact all business in the Patent and Trailemark Office connected therewith and to file, prosecute and to transact all business in connection with international applications directed to said invention:

	of billian or one or	Data Involution				
, , ,	William L. Mathis Reterit S. Swecker Plater N. Mandros Benjon S. Duffrett, Jr. Joseph R. Magnone Norman H. Stepno Ronald L. Grudziecki Frederick G. Michaud, Jr. Alande. Kopecki	17,337 15,913 19,885 22,124 22,030 24,239 22,716 24,970 26,003 25,813	Robert G. Mukai George A. Hovanec, Jr. James A. LaBarre E. Joseph Gess R. Danny Huntington Erie H. Weisblatt James W. Peterson Teresa Stanek Rea Robert E. Krebs William C. Rowland	28.531 28.223 28.632 28.510 27.903 30.505 26.057 30.427 25.885 30.888	William H. Benz Peter K. skiff Rechard J. McGrath Matthew L. Schneider Michael G. Savage Gerald F. Swies Michael J. Ure Charles F. Wieland III Bruce T. Wieder Todd R. Walters	25,952 31,917 29,195 32,814 32,596 30,113 33,089 33,096 33,515 34,040
	Alanki. Kopecki Regip.E. Slutter Samuel C. Miller, III Ralph-L. Freeland, Jr.					33,815
ļ	and.				\	

Address all correspondence to:

Robert G. Mukai BURNS, DOANE, SWECKER & MATHIS, L.L.P. P.O.Box 1404

Alexandria, Virginia 22313-1404

Address all telephone calls to: Robert G. Mukai at (703)836-6620.

I hereby declare that all statements made herein of my own knowledge are true and that all statements made on information and belief are believed to be true; and further that these statements were made with the knowledge that willful false statements and the like so made are punishable by fine or imprisonment, or both, under Section 1001 of Title 18 of the United States Code and that such willful false statements may jeopardize the validity of the application or any patent issued thereon.

,co	MBINED DECLARATION FOR PATENT APPLICATION AN	D POWER OF ATTORNEY (CONTI	MUED)	Attorney Docket No.
(In	cludes Reference to Provisional and PCT International applic	ations)	,	
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1 1/2	Takeya ABE	Signature	Dat	
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١ -	Chiba YX	•	1	Japan
1	Post Office Address			
	c/o Mitsui Chemicals, Inc., 1900, Togo, Mo	bara-shi, Chiba, 297-8666 J	apan	
(2)	Full Name of Second Inventor	Signature	Dat	<u> </u>
	Kiyoshi ITOU	Kujahi Hou		26 9 2001
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(3)	c/o Mitsui Chemicals, Inc., 1144, Togo, Mo Full Name of Third Inventor	bara-shi, Chiba, 297-0017 J	apan	
1/3		Signature	Date	9
00	Kenju SASAKI	Kenju Susaki		24.7.2001
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(4)	Full Name of Fourth Inventor	Cignotus		
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From the INTERNATIONAL BUREAU

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NOTIFICATION OF RECEIPT OF **RECORD COPY**

(PCT Rule 24.2(a))

MOGAMI, Shotaro Nagatani City Plaza 201 8-1, Akasaka 1-chome Minato-ku, Tokyo 107-0052 **JAPON**



Date of mailing (day/month/year) 15 February 2001 (15.02.01)	IMPORTANT NOTIFICATION
Applicant's or agent's file reference F-1892	International application No. PCT/JP01/00131

The applicant is hereby notified that the International Bureau has received the record copy of the international application as

Name(s) of the applicant(s) and State(s) for which they are applicants:

MITSUI CHEMICALS, INC. (for all designated States except US) ABE, Takeya et al (for US)

International filing date

12 January 2001 (12.01.01)

Priority date(s) claimed

17 January 2000 (17.01.00)

Date of receipt of the record copy by the International Bureau

29 January 2001 (29.01.01)

List of designated Offices

EP:DE,FR,GB,NL National : KR, US

ATTENTION

The applicant should carefully check the data appearing in this Notification. In case of any discrepancy between these data and the indications in the international application, the applicant should immediately inform the international Bureau.

In addition, the applicant's attention is drawn to the information contained in the Annex, relating to:

time limits for entry into the national phase

confirmation of precautionary designations

requirements regarding priority documents

A copy of this Notification is being sent to the receiving Office and to the International Searching Authority.

The International Bureau of WIPO 34, chemin des Colombettes 1211 Geneva 20, Switzerland

Masaetti HOND

Facsimile No. (41-22) 740.14.35

Telephone No. (41-22) 338.83.38

Authorized officer:

(12)特許協力条約に基づいて公開された国際出願

(19) 世界知的所有権機関 国際事務局



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(43) 国際公開日 2001年7月26日 (26.07.2001)

PCT

(10) 国際公開番号 WO 01/53253 A1

Takeya) [JP/JP]. 佐々木賢樹 (SASAKI, Kenju) [JP/JP].

渡辺清一 (WATANABE, Seiichi) [JP/JP]; 〒297-8666

千葉県茂原市東郷1900番地 三井化学株式会社内 Chiba (JP). 伊藤 潔 (ITOU, Kiyoshi) [JP/JP]. 浅野

保 (ASANO, Tamotsu) [JP/JP]; 〒297-0017 千葉県茂原

神奈川県横浜市神奈川区金港町5番地,36 東興ビル5

市東郷1144番地 三井化学株式会社内 Chiba (JP).

(74) 代理人: 苗村新一(NAEMURA, Shinichi); 〒221-0056

(51) 国際特許分類?: C07C 231/24, 233/09, C12P 13/02 // C07C 231/06, C12N 15/60, (C12N 15/60, C12R·1:19) (C12P 13/02, C12R 1:19)

(21) 国際出願番号:

PCT/JP01/00131

(22) 国際出願日:

2001年1月12日(12.01.2001)

(25) 国際出願の言語:

日本語

(26) 国際公開の言語:

日本語

(30) 優先権データ:

特願2000-7993 2000年1月17日 (17.01.2000) JP

(71) 出願人 (米国を除く全ての指定国について): 三井化 学株式会社 (MITSUI CHEMICALS, INC.) [JP/JP]; 〒 100-6070 東京都千代田区霞が関三丁目2番5号 Tokyo (JP).

(81) 指定国 (国内): KR, US.

(84) 指定国 (広域): ヨーロッパ特許 (DE, FR, GB, NL).

添付公開書類:

国際調査報告書

階 Kanagawa (JP).

(72) 発明者; および

(75) 発明者/出願人 (米国についてのみ): 阿部剛也 (ABE,

2文字コード及び他の略語については、 定期発行される 各PCTガゼットの巻頭に掲載されている「コードと略語 のガイダンスノート」を参照。

(54) Title: METHOD OF PURIFYING AMIDE COMPOUND

(54) 発明の名称: アミド化合物の精製方法

(57) Abstract: A method of efficiently eliminating impurities contained in an amide compound-containing solution (in particular, an amide compound-containing solution prepared by hydrating a nitrile compound by using optionally processed microbial cells containing nitryl hydratase) which comprises bringing the solution into contact with active carbon under acidic conditions.

(57) 要約:

本発明は、アミド化合物含有液、特にニトリルヒドラターゼを含有する微生物 菌体、または該微生物菌体の処理物を用いてニトリル化合物の水和反応で製造さ れたアミド化合物含有液を、酸性の条件下において、活性炭と接触処理すること により、アミド化合物含有液中に含まれる不純物を効率的に除去する方法を提供